

PATENT NUMBER

O.I.P.E. M.H. <i>gm</i> SCANNED <i>gm</i> Q.A. <i>LR</i>	PATENT DATE
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APPLICATION NO. 09/692606	CONT/PRIOR	CLASS 438	SUBCLASS 2173	ART UNIT T765 T775	EXAMINER K1600 B1738
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APPLICANTS

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Layer transfer of low defect SiGe using an etch-back process

PTO-2040
12/89

ISSUING CLASSIFICATION									
ORIGINAL				CROSS REFERENCE(S)					
CLASS		SUBCLASS		CLASS		SUBCLASS (ONE SUBCLASS PER BLOCK)			
INTERNATIONAL CLASSIFICATION									

☐ Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____ _____	_____ (Primary Examiner) _____ (Date)			ISSUE FEE	
				Amount Due	Date Paid
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